First Preliminary Amendment

AMENDMENTS TO THE CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of Claims:

Claim 1 (original): A gas barrier film comprising a thermoplastic polymer film, and an inorganic thin film provided on at least one surface of the thermoplastic polymer film, which gas

barrier film is formed by applying, to the inorganic thin film, a solution which contains at least one

ion species selected from the group consisting of alkali metal ions, alkaline earth metal ions, and

ammonium ions and originating from a low-molecular-weight electrolyte having a molecular weight

of 1.000 or less and which has a total ion concentration of 1×10^{-5} mol/L or more and less than 10

mol/L and a solution concentration less than a saturation concentration.

Docket No.: 20699/0204307-US0

Claim 2 (original): A gas barrier film as described in claim 1, wherein the total ion concentration of at least one ion species selected from the group consisting of alkali metal ions,

alkaline earth metal ions, and ammonium ions and originating from a low-molecular-weight

electrolyte having a molecular weight of 1,000 or less is 1 × 10⁻⁴ mol/L or more and less than 1 ×

10⁻¹ mol/L, and the solution concentration is less than a saturation concentration.

Claim 3 (original): A gas barrier film comprising a thermoplastic polymer film, and an

inorganic thin film provided on at least one surface of the thermoplastic polymer film, which gas barrier film is formed by applying, to the inorganic thin film, a solution which contains at least one

ion species selected from the group consisting of alkali metal ions, alkaline earth metal ions, and

ammonium ions and originating from a low-molecular-weight electrolyte having a molecular weight

of 1,000 or less such that the total weight of the ion species in a film area of 1.00 m² is adjusted to

1.0 µg to 30 g.

Claim 4 (currently amended): A gas barrier film as described in any one of claimsclaim 1-to

3, wherein the inorganic thin film contains silicon oxide.

Docket No.: 20699/0204307-US0

Claim 5 (original): A gas barrier film comprising a thermoplastic polymer film, and an inorganic thin film provided on at least one surface of the thermoplastic polymer film, wherein the thin film has a total alkali metal ion and alkaline earth metal ion concentration in a film area of 1.00 m², as determined through inductively coupled plasma Auger electron spectroscopy (ICP-AES), of 2.0 ug to 1.000 µg₂.

Claim 6 (original): A gas barrier film as described in claim 4, wherein the thin film containing silicon oxide has a ratio of total ion intensity A to ion intensity B (A/B), as determined by means of a time-of-flight secondary ion mass spectrometer (TOF-SIMS), is $0.20 \le A/B \le 100$, wherein ion intensity A represents the sum of peak intensities attributed to total alkali metal ions, alkaline earth metal ions, and ammonium ions contained in the thin film, and ion intensity B represents a peak intensity attributed to 30 Si.

Claim 7 (original): A gas barrier film as described in claim 4, wherein the thin film containing silicon oxide has a ratio of ion intensity C to ion intensity B (C/B), as determined by means of a TOF-SIMS, of $0.04 \le C/B \le 0.50$, wherein ion intensity B represents a peak intensity attributed to 30 Si, and ion intensity C represents a peak intensity attributed to 30 SiOH-

Claim 8 (currently amended): A gas barrier film as described in any-one-of-elaimsclaim 1-to 7, which is formed by applying, to the inorganic thin film, a mixture solution containing a solution which contains at least one ion species selected from the group consisting of alkali metal ions, alkaline earth metal ions, and ammonium ions and originating from a low-molecular-weight electrolyte having a molecular weight of 1,000 or less and a solution which contains at least one species selected from a resin and a metal oxide sol.

Claim 9 (currently amended): A gas barrier film as described in any one of elaimsclaim 1-to 7, which is formed by applying, to the inorganic thin film, a solution which contains at least one ion species selected from the group consisting of alkali metal ions, alkaline earth metal ions, and

ammonium ions and originating from a low-molecular-weight electrolyte having a molecular weight of 1.000 or less, to thereby form a layer, and by forming thereon a resin solution coating layer.

Claim 10 (currently amended): A gas barrier film as described in any one of claimsclaim 1 to 9, which is formed by applying, to the inorganic thin film, a solution which contains at least one ion species selected from the group consisting of alkali metal ions, alkaline earth metal ions, and ammonium ions and originating from a low-molecular-weight electrolyte having a molecular weight of 1,000 or less, and, subsequently, carrying out heat treatment at 60°C or higher.

Claim 11 (currently amended): A method for producing a gas barrier film, which method comprises the steps of:

forming an inorganic thin film on at least one surface of a thermoplastic polymer film and, subsequently, applying, to the inorganic thin film, a solution which contains at least one ion species selected from the group consisting of alkali metal ions, alkaline earth metal ions, and ammonium ions and originating from a low-molecular-weight electrolyte having a molecular weight of 1,000 or less and which has a total ion concentration of 1×10^{15} mol/L or more and less than 10 mol/L and a solution concentration less than a saturation concentration.

Claim 12 (currently amended): A method for producing a gas barrier film, which method comprises the steps of:

forming an inorganic thin film on at least one surface of a thermoplastic polymer film and, applying, to the inorganic thin film, a solution which contains at least one ion species selected from the group consisting of alkali metal ions, alkaline earth metal ions, and ammonium ions and originating from a low-molecular-weight electrolyte having a molecular weight of 1,000 or less such that the total weight of the ion species in a film area of 1.00 m² is adjusted to 1.0 μ g to 30 g.

Claim 13 (new): A gas barrier film as described in claim 3, wherein the inorganic thin film contains silicon oxide.

Application No. National Phase of PCT/JP2004/017680 7 Amendment dated May 11, 2006

First Preliminary Amendment

Claim 14 (new): A gas barrier film as described in claim 13, wherein the thin film

Docket No.: 20699/0204307-US0

containing silicon oxide has a ratio of total ion intensity A to ion intensity B (A/B), as determined

by means of a time-of-flight secondary ion mass spectrometer (TOF-SIMS), is 0.20 ≤ A/B ≤ 100,

wherein ion intensity A represents the sum of peak intensities attributed to total alkali metal ions,

alkaline earth metal ions, and ammonium ions contained in the thin film, and ion intensity B

represents a peak intensity attributed to 30Si.

Claim 15 (new): A gas barrier film as described in claim 13, wherein the thin film

containing silicon oxide has a ratio of ion intensity C to ion intensity B (C/B), as determined by means of a TOF-SIMS, of $0.04 \le C/B \le 0.50$, wherein ion intensity B represents a peak intensity

include of a Tot-Birtis, of 0.04 2 0/2 2 0.50, wherein for intensity is represents a peak in

attributed to $^{30}\mathrm{Si},$ and ion intensity C represents a peak intensity attributed to $^{30}\mathrm{SiOH}.$

Claim 16 (new): A gas barrier film as described claim 5, which is formed by applying, to

the inorganic thin film, a mixture solution containing a solution which contains at least one ion

species selected from the group consisting of alkali metal ions, alkaline earth metal ions, and ammonium ions and originating from a low-molecular-weight electrolyte having a molecular weight

of 1,000 or less and a solution which contains at least one species selected from a resin and a metal

oxide sol.

Claim 17 (new): A gas barrier film as described claim 5, which is formed by applying, to the

inorganic thin film, a solution which contains at least one ion species selected from the group

consisting of alkali metal ions, alkaline earth metal ions, and ammonium ions and originating from a

low-molecular-weight electrolyte having a molecular weight of 1,000 or less, to thereby form a

layer, and by forming thereon a resin solution coating layer.

Claim 18 (new): A gas barrier film as described claim 5, which is formed by applying, to

the inorganic thin film, a solution which contains at least one ion species selected from the group

consisting of alkali metal ions, alkaline earth metal ions, and ammonium ions and originating from a

Application No. National Phase of PCT/JP2004/017680 8 Amendment dated May 11, 2006 First Preliminary Amendment

low-molecular-weight electrolyte having a molecular weight of 1,000 or less, and, subsequently, carrying out heat treatment at 60°C or higher.

Docket No.: 20699/0204307-US0